



ECS 19

EUROPEAN COATING SYMPOSIUM HEIDELBERG

13th ECS in Germany - Heidelberg - Karlsruhe

September 8th - 11th, 2019

Marriot Hotel, Vangerowstr. 16, Heidelberg



Advances in Coating & Drying of Thin Films, Smart Coatings & Materials

- Li-Ion Battery Material Coatings
- New Anode / Cathode / Separator Material Coatings
- Printed Electronics for Energy Harvesting
- Digital Printing, Ink Jet Technology
- Liquid Drop Jetting and Aerosol Printing Technologies
- 3D Lithographic Printing and Additive Manufacturing
- 3D Multilayer Stacking Technologies
- Fundamentals in Film Drying, Diffusion, Heat & Mass Transfer
- Paints, Varnishes, Adhesives
- Superhydrophobic Materials, Self-assembling Coatings
- Bioactive Polymers, Coatings and Sensors
- Hybrid Inorganic/Organic & Protein Coatings
- Self-healing and Shape-Memory Coatings
- Electroconductive Polymers and Coatings
- Thermo-Active, Stimuli Responsive & Photochromic Materials

ECS 2019 CHAIRS: Prof. Dr.-Ing. Dr. h.c. Wilhelm Schabel (KIT)
Dr.-Ing. Philip Scharfer (KIT)
organized by GVT (DECHEMA)



Registration

Online registration will be available soon at <http://www.european-coating-symposium.eu>

Deadline for early bird registration is May 1st, 2019.

Fees:	early bird	later
Industry	€ 850.-	€ 950.-
University Academics	€ 650.-	€ 750.-
Students	€ 400.-	€ 500.-

incl. ECS boat ride, dinner & sponsored reception
ECS Sponsors & Exhibitors please contact us

Venue

The Symposium will take place at the Marriot Hotel, Vangerowstraße 16, 69115 Heidelberg Germany.

For participants of the European Coating Symposium rooms are available at reduced rates under the reference "ECS 2019":

Single room*	*breakfast included	€155.-
Double room*		€170.-

Call for Abstracts

For an oral presentation or poster, please submit an abstract to ecs2019@lists.kit.edu (1 pdf page) before April 1st, 2019

(Templates available at the ECS website)

After acceptance of the abstract, you will be asked to submit a 1-2 pages extended abstract before July 1st, 2019.

Contact

Organisation: ecs2019@lists.kit.edu

Registration: Hipp@dechema.de

Local Organisation & Registration Team:

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